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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/559,757	04/27/2000	Yoshio Ozawa	04329.2306	2923	
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FINNEGAN, HENDERSON, FARABOW, GARRETT & DUNNER LLP 1300 I STREET, NW WASHINGTON, DC 20005			PHAM, THANH V		
			ART UNIT	PAPER NUMBER	
			2823		
			DATE MAILED: 01/11/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

1) ⊠ Responsive to communication(s) filed on 10 November 2004. 2a) ⊠ This action is FINAL. 2b) ☐ This action is non-final. 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) ☒ Claim(s) 8-21 is/are pending in the application. 4a) Of the above claim(s) 16-19 is/are withdrawn from consideration. 5) ☐ Claim(s)		Application No.	Applicant(s)				
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- The MALING DATE of this communication appears on the cover sheet with the correspondence address — Period for Repty A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MALING DATE OF THIS COMMUNICATION. Exherence of the marple a varieties under the provisions of 37 CPR 1.13(g), in no evert, however, may a raphy be timely filled state of the communications of 37 CPR 1.13(g), in no evert, however, may a raphy be timely filled state of the communications of the provision of the communication of the provision of the provision of the communication of the provision of the provision of the communication of the provision of the provision of the communication of the provision of the provision of the communication of the provision of the above claim(s) 16-19 is/are withdrawn from consideration. 4) ② Claim(s) 8-21 is/are pending in the application. 4) ② Claim(s) 8-21 is/are pending in the application. 4) ② Claim(s) 8-15 20 and 21 is/are rejected. 7) □ Claim(s) 8-15 20 and 21 is/are rejected. 7) □ Claim(s) 8-15 20 and 21 is/are rejected. 7) □ The draving(s) filled on 15 is/are: a) □ accepted or b) □ objected to by the Examiner. Application Papers 9) □ The specification is objected to by the Examiner. 10) □ The draving(s) filled on 15 is/are: a) □ accepted or b) □ objected to by the Examiner. Application Papers 9) □ The cath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 11) □ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) □ All b) □ Some * ○ □ None of: □ □ Certified copies of the priority documents have been received in Application No. □ □ Certified copies of the priority documents have been received in Application No. □	Oπice Action Summary	Examiner	Art Unit				
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Application/Control Number: 09/559,757 Page 2

Art Unit: 2823

DETAILED ACTION

Response to Amendment

- 1. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.
- 2. Claims 8-15 and 20-21 are rejected under 35 U.S.C. 103(a) as being unpatentable over applicants' admitted prior art in combination with Hisamune US Patent No 6,414,352
- B1, Aminzadeh et al. US Patent No 6,707,120 B1 and Wolf et al., Silicon Processing for VLSI Era, vol. 1, chapters 6-7.

In the description of the prior art of fig. 15, the applicants disclose that an insulating film containing silicon and nitrogen 95 is formed on the substrate 91; a film which must be processed and which contains silicon 93 is formed on the insulating film; those films are processed such that a portion of the insulating film is exposed to the outside; the structure obtained in the previous steps is subjected to an oxidation process (the instant specification, page 7, lines 4-5; page 18, lines 21-22; page 20, line 26 to page 21, line 1).

The applicants' admitted prior art does not provide, in the oxidation step, a surface of the semiconductor substrate is lowered, oxidizing gas containing one of ozone and oxygen radicals, the oxygen radicals being generated by remote plasma oxidizing method or by reacting a first gas containing oxygen and a second gas containing hydrogen (the added limitation in the amended claims 8 and 12).

The Hisamune reference discloses oxidation processes are required after forming the gates and recognizes that, in the <u>conventional</u> oxidation processes, oxygen radical created within a furnace easily **diverges** through the separating regions in the form of silicon dioxide and reaches the gates. This encroachment of the oxide into the bottom of the gates is known as a "gate bird's beak" because of its shape when viewed in cross-section (col. 2, line 64 to col. 3, line 7). The teaching of Hisamune accords with the teaching of Wolf et al. pages 198, 202, 211, 215-221, 227-228 on Thermal Oxidation, chapter 7 wherein the surface of the semiconductor substrate is lowered (fig. 3, page 202) and pages 183-187, 191-195 on Chemical Vapor reaction, chapter 6 wherein plasma oxidation and oxygen/hydrogen reacting are taught (fig. 7, page 171, fig. 6, page 170, fig. 8, page 172, page 184 and fig. 18, page 186, e.g.).

The applicant's admitted prior art teaches "bird's beak oxidation owing to the post oxidation" (the instant specification, page 20's last line), the Hisamune reference also concerns about the gate bird's beak free technology (col. 1, line 9 and col. 3, line 6). To employ the oxidation process with conventional oxidizing gas containing one of ozone and oxygen radicals of Hisamune, supported by Wolf et al., to the oxidation process of applicants' admitted prior art would have been obvious to one of ordinary skill in the art as the oxidizing gas containing one of ozone and oxygen radicals, the oxygen radicals being generated by remote plasma oxidizing method (Wolf's fig. 6, page 170, fig. 7, page 171, fig. 8, page 172, e.g.) or by reacting a first gas containing oxygen and a second gas containing hydrogen (Wolf's page 184 and fig. 18, page 186, e.g.), as recognized as conventional by Hisamune would be selected in order to lower the

surface of the semiconductor substrate, to have a bird-beak free in insulating layer (Hisamune's col. 1, line 9) in accordance with the oxidation step as taught by applicants' admitted prior art.

"Lowering a surface of the semiconductor substrate under a part of the insulating film than a surface of the semiconductor substrate under the film which is processed to cause the portion of the insulating film to be exposed to the outside by applying a thermal oxidation process to a semiconductor structure obtained in the step of an oxidation process by using the oxidizing gas containing one of ozone and oxygen radicals" is inherent as recognized by Aminzadeh et al. (The inherency of this "lowering the surface" is supported by Wolf et al.'s fig. 3, page 202.)

Re claim 20-21, the Wolf et al. reference, in fig. 4, page 205, teaches a plot at various temperatures between 700 and 1300 °C as a function of oxidation time.

Choice of temperature within a particular time frame would have been a matter of routine optimization because temperature and time are known to affect device properties and would depend on the desired device density on the finished wafer and the desired device characteristics. One of ordinary skill in the art would have been led to the recited temperature through routine experimentation to achieve desired deposition and reaction rates.

Although Wolf et al. teaches broadly nitridation of silicon dioxide (page 210), the reference does not teach the step of subjecting this particular structure to at least one of a nitriding process and an additional oxidation process. "Improvement in the quality of

the film owing to recovery of the process damage becomes insufficient" (applicant's admitted prior art, page 21, lines20-22).

The Aminzadeh et al. reference discloses a process of Kusunoki et al. in IEEE IEDM, vol. 91, wherein the re-oxided nitrided oxide applied on the gate structure could increase the thickness of side oxide 201, fig. 2 and last line of col. 1. With its own invention, the Aminzadeh et al. reference discloses "the poly reox step forms oxide 600 on the gate electrode 403, and also increase the thickness of gate oxide 404 over the areas that will become the source and drain regions", col. 3, last line to col. 4, line 2. The "oxide 600 is then nitridated to strengthen the oxide", "the nitridation can be performed in a furnace or a RTP", col. 4, lines 22 and 34-35. The gate structure is subjected to the oxidizing process to at least one of nitriding process and an additional oxidation process as in fig. 7 and the related explanation in col. 4, line 42 to col. 6, line 30.

It would have been obvious to one of ordinary skill in the art at the time the invention was made to apply further the nitridation and anneal steps of Aminzadeh et al. into the above combination of Hisamune with applicants' admitted prior art as a further process step would be selected in order to strengthen the gate dielectric film in accordance with the oxidation step as taught by Aminzadeh et al.

The concentration of 5×10^{13} cm⁻² nitrogen in the interface of silicon oxynitride film with the silicon substrate would have been an obvious matter of design choice bounded by well known manufacturing constraints and ascertainable by routine experimentation and optimization to choose this particular concentration to overcome

applicants' admitted prior art constraint (specification's page 21), and it appears that the process would possess utility using this concentration.

Response to Arguments

- 3. Applicant's arguments filed 11/10/2004 have been fully considered but they are not persuasive.
- 4. In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See In re Keller, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); In re Merck & Co., 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986). Applicant's first argument on page 8 attacks Hisamune's invention while the rejection uses Hisamune's teaching on the required oxidation processes after forming the gates and Hisamune's recognization that, in the conventional oxidation processes, oxygen radical created within a furnace easily diverges through the separating regions in the form of silicon dioxide and reaches the gates. This encroachment of the oxide into the bottom of the gates (known as a "gate bird's beak" because of its shape when viewed in cross-section, col. 2, line 64 to col. 3, line 7) is in combination with applicant's admitted prior art of the structure prior to thermal oxidation.
- 5. Applicant's arguments with respect to the "thermal oxidation processes using an oxidizing gas containing one of ozone and oxygen radicals, the oxygen radicals being generated by remote plasma oxidizing method or by reacting a first gas containing oxygen and a second gas containing hydrogen" in the second argument in the

paragraph bridged page 8 and page 9; the added term "remote" in the amended claims changes the scope of the claim and is treated differently as in the rejection above.

6. In response to applicant's third and fourth arguments on pages 9-10, these arguments are respectfully traversed because, although not taught as a preferred embodiment, Hisamune teaches this embodiment nonetheless, and disclosed examples and preferred embodiments do not constitute a teaching away from a broader disclosure or nonpreferred embodiments. In re Susi, 169 USPQ 423 (CCPA 1971). "A known or obvious composition does not become patentable simply because it has been described as somewhat inferior to some other product for the same use." In re Gurley, 31 USPQ2d 1130, 1132 (Fed. Cir. 1994). A reference may be relied upon for all that it would have reasonably suggested to one having ordinary skill the art, including nonpreferred embodiments. Merck & Co. v. Biocraft Laboratories, 874 F.2d 804, 10 USPQ2d 1843 (Fed. Cir.), cert. denied, 493 U.S. 975 (1989). Even a teaching away from a claimed invention does not render the invention patentable. See Celeritas Technologies Ltd. v. Rockwell International Corp., 150 F.3d 1354, 1361, 47 USPQ2d 1516, 1522-23 (Fed. Cir. 1998), where the court held that the prior art anticipated the claims even though it taught away from the claimed invention. "The fact that a modem with a single carrier data signal is shown to be less than optimal does not vitiate the fact that it is disclosed." To further clarify, a prior art opinion that a claimed invention is not preferred for a particular limited purpose, does not preclude utility of the invention for that or another purpose, or even preferability of the invention for another purpose.

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7.

applicant also requests a proof of inherency, Fig. 3 on Wolf et al.'s page 202 is attached

In response to applicant's fifth and final arguments on pages 10-11 in which

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as one for the limitation of "lowering a surface of the semiconductor substrate under the

insulating film by applying a thermal oxidation process to a semiconductor structure

obtained". The re-oxided nitrided oxide applied on the gate structure could increase the

thickness of side oxide 201 as pointed out by Aminzadeh et al. (fig. 2 and last line of col.

1) about the prior art of Kusunoki et al. is the same performance of the instant invention

would provide the lowering the surface of the obtained semiconductor substrate. It is

neither conclusory nor blanket generalization concluding in the rejection as argued

herewith.

Conclusion

- The prior art made of record and not relied upon is considered pertinent to 8. applicant's disclosure.
- THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time 9. policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of

the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

10. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thanh V. Pham whose telephone number is 571-272-1866. The examiner can normally be reached on M-Th (6:30-5:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

01/03/2005